



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

April 11, 2026

IGI Report Number

LG789637422

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

CUSHION MODIFIED BRILLIANT

Measurements

10.34 X 7.46 X 4.97 MM

GRADING RESULTS

Carat Weight

3.09 CARATS

Color Grade

E

Clarity Grade

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG789637422

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

PROPORTIONS

Medium To Slightly Thick (Faceted)

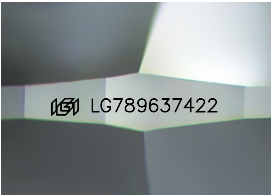
14%

49.5%

63%

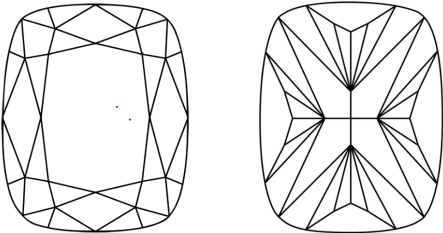
66.6%

Pointed



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

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